

Electric-field-induced reflection in silver accompanying generation of the giant second harmonic

O. A. Aktsipetrov, E. D. Mishina, and A. V. Petukhov

M. V. Lomonosov State University, Moscow

(Submitted 6 May 1983)

Pis'ma Zh. Eksp. Teor. Fiz. **37**, No. 12, 592–594 (20 June 1983)

The dependence of the intensity of the surface-enhanced second harmonic on the magnitude of the constant electric field [not observed by T. F. Heinz *et al.*, *Chem. Phys. Lett.* **83**, 1 (1981)] is observed.

PACS numbers: 78.20.Jq

Surface enhancement of the second harmonic (SH), generated with reflection of light from a rough silver surface, was first observed by Chen *et al.*^{1,2} This phenomenon is closely related to giant Raman scattering of light (GRS) and is caused by the increase in the local field $E_l(\omega) = L(\omega) E(\omega)$ accompanying resonant excitation of surface plasmons in a metal with incident radiation $E(\omega)$, where $L(\omega)$ is the local field factor. For a rough metal surface, the local field factor has the form

$$L(\omega) = [\epsilon_M(\omega) - \epsilon_{av}(\omega)] [\epsilon_M(\omega) + \eta \epsilon_{av}(\omega)]^{-1},$$

where ϵ_M , ϵ_{av} are the complex dielectric constants of the metal and of the surrounding medium, and $\eta \sim 10$ is a coefficient that depends on the geometry of the surface inhomogeneities.^{2,3} When the pumping radiation is in resonance with the local surface plasmons, $\text{Re}[\epsilon_M(\omega) + \eta \epsilon_{av}(\omega)] = 0$ and the local field factor $L(\omega) \sim \text{Im}[\epsilon_M(\omega) + \eta \epsilon_{av}(\omega)]^{-1}$ increases in a resonant manner.

The polarization of the surface layer of the metal, including the local field factor, is determined by the expression

$$P(2\omega) = L(2\omega)L^2(\omega) \chi_{\text{eff}}^{(2)}(2\omega; \omega, \omega) E^2(\omega),$$

where $\chi_{\text{eff}}^{(2)}$ is the effective quadratic susceptibility of the metal (including the quadrupolar susceptibility for media with an inversion center). At resonance $L(\omega) \sim 10$ and the intensity of SH with reflection from a rough metal surface $I_{2\omega}$ increases by four orders of magnitude compared to SH generated on a smooth surface. Such surface enhancement of $I_{2\omega}$, by analogy with GRS, can be called generation of giant SH.

A constant electric field E_0 , applied to the surface, changes ϵ_M due to the contribution of cubic susceptibility $\chi^{(3)}(\omega; \omega, 0, 0) E_0^2$ and thereby changes the magnitude of the local field factor. The quadratic susceptibility of the metal also changes when a constant electric field is applied due to the contribution of $\chi^{(3)}(2\omega; \omega, \omega, 0) E_0$. Both factors must change the intensity of the giant SH with the application of E_0 . This dependence of $I_{2\omega}$ on the electric field could be caused by electric-field-induced reflection accompanying generation of the giant SH. However, the dependence $I_{2\omega}(E_0)$ was not observed in Ref. 1.

We investigated electric-field-induced reflection accompanying generation of gi-

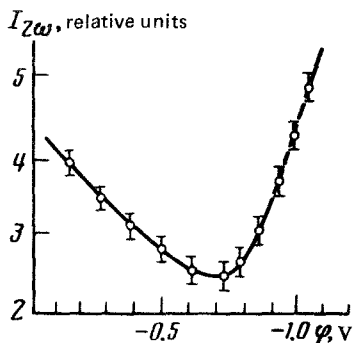


FIG. 1. Dependence of the giant SH intensity on the voltage drop φ across the silver-electrolyte interface.

ant SH from the surface of silver. The controlled roughness was deposited on the metal surface by anodic etching in an electrolytic solution of KCl with a concentration of 0.1 mole/liter. The charge density, transferred over one anode cycle, for which the gain in the SH intensity reached saturation $\sim 10^4$, was $q = 100 \text{ mC/cm}^2$. Investigation of the silver surface with an electron microscope showed the presence of roughness with characteristic size $\sim 1000 \text{ \AA}$. The constant electric field was applied to the surface of the metal by applying a voltage across the electrolyte between the silver and the auxiliary platinum electrode. With this method, it was possible to achieve fields $E_0 \sim 10^6\text{--}10^7 \text{ V/cm}^2$ across the metal-electrolyte interface.⁴

We observed the generation of giant SH with reflection of a single mode YAG:Nd³⁺ laser pulse with wavelength $\lambda = 1060 \text{ nm}$, pulse duration 15 ns, and energy density $\sim 5 \text{ mJ/cm}^2$. The SH radiation with $\lambda = 530 \text{ nm}$, collected at the input slit of a DFS-24 monochromator, was recorded by a strobe amplitude-digital converter.

Figure 1 shows the dependence of $I_{2\omega}$ on the voltage drop φ in the Helmholtz layer at the silver-electrolyte interface (the potential φ was measured relative to a chlorine-silver comparison electrode). It is well known that a constant electric field E_0 in the Helmholtz layer vanishes at some value of the potential φ_l , called the zero-charge potential. For silver in a KCl solution, we have $\varphi_l = -0.76 \text{ V}$.⁵ The value of the potential φ_{min} , at which a minimum is observed in the intensity of the giant SH, agrees well with the quantity φ_l . As $\Delta\varphi = |\varphi - \varphi_l|$ is increased, the field E_0 in the Helmholtz layer increases, reaching magnitudes of $\sim 10^7 \text{ V/cm}$ at $\Delta\varphi \sim 1$, which is what leads to the increase in $I_{2\omega}$.

The ionic layer in the electrical double-layer at the metal-electrolyte interface can contribute to $I_{2\omega}$, together with the surface layer of the metal. The dependence of $I_{2\omega}$ on the field E_0 is apparently determined primarily by the contribution of the metal due to the large values of $\chi^{(3)}$ for silver,⁶ but the asymmetry of the curve $I_{2\omega}(\varphi)$ relative to φ_l could be related to the contribution of the Helmholtz layer, which has a different structure for $\varphi < \varphi_l$ and $\varphi > \varphi_l$. The interference of nonlinear contributions of the component parts of the electrical double layer could shift the position of the minimum in $I_{2\omega}(\varphi)$, which must be taken into account when measuring φ_l by the method of giant SH generation.

Thus we have observed for the first time electric-field-induced reflection accompanying generation of surface-enhanced SH. Based on this phenomenon, a nonlinear-optical method for measuring the zero-charge potential of the metal is proposed.

In conclusion, we thank L. V. Keldysh for formulating the problem and for useful discussions.

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Translated by M. E. Alferieff

Edited by S. J. Amoretty